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Preliminary communication

AN ESR STUDY OF THE REACTIONS OF TRIALKYLSILOXYL AND TRIALKYLSILYL RADICALS WITH DIALKYL SULPHIDES

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Summary

Trimethylsiloxyl radicals add to dialkyl sulphides to produce sulphuranyl radicals, whilst triethylsilyl radicals bring about homolytic dealkylation of dialkyl sulphides.

The major reaction between t-butoxyl radicals and dialkyl sulphides of the type $(R_2CH)_2S$ (R = H, alkyl, or aryl) involves abstraction of an α -hydrogen to form the radicals R_2CSCHR_2 (I), although attack at sulphur may be responsible for the ultimate formation of the sulphuranyl radicals $R_2CHS(OBu-t)_2$ which have been detected by ESR spectroscopy [1]^{*}.

t-BuOOBu-t
$$\xrightarrow{n\nu}$$
 2 t-BuO' (1)

t-BuO' + $(R_2CH)_2S \longrightarrow$ t-BuOH + $R_2\dot{C}SCHR_2$ (2)

(I)

For example, when a cyclopropane solution containing di-t-butyl peroxide and dimethyl sulphide is irradiated with UV light whilst the sample is in the cavity of an ESR spectrometer the spectrum of the radical (I; R = H) is detected.

However, when the di-t-butyl peroxide was replaced by bis(trimethylsilyl) peroxide [3] overlapping spectra from I; R = H and from a radical showing a(6H) 7.7 G, g 2.0076 at 210 K were obtained. We assign the new signal to the sulphuranyl radical adduct II; $R = H^{**}$.

^{*}The strained cyclic sulphide thietan undergoes attack at sulphur and ring-opening to yield the radical t-BuOSCH₂CH₂CH₂[•] [2].

^{**}A less likely alternative would be the sulphyranyl radical (R₂CH)₂(ME₃SiO)SS(CHR₂)₂, produced by association of II with a second molecule of sulphide. Further work is in progress to distinguish between these two structures.

$$\rightarrow$$
R₂CSCHR₂ + Me₃SiOH

 $Me_3SiO' + (R_2CH)_2S -$

→(R₂CH)₂ŠOSiMe₃

(II)

A similar competition between addition to sulphur and abstraction of hydrogen was observed for the reactions of trimethylsiloxyl radicals with a variety of dialkyl sulphides, and the results are summarised in Table 1. The ESR parameters for the sulphuranyl adducts of the type II are given in Table 2. It is not possible to deduce the detailed structure of II from the present isotropic ESR data. The S-alkyl groups could be equivalent (apart from possible conformational effects) with the unpaired electron in a σ^* -S—O orbital,

TABLE 1

RADICALS DETECTED BY ESR SPECTROSCOPY DURING THE REACTIONS OF TRIMETHYL-SILOXYL OR TRIETHYLSILYL RADICALS WITH DIALKYL SULPHIDES AT ca. 213 K IN CYCLOPROPANE

| Sulphide | Radicals detected with co-reactants | | |
|---------------------|---|--|--|
| | Me ₃ SiOOSiMe ₃ ^{<i>a</i>} | t-BuOOBu- t + Et ₃ SiH ^{b,c} | |
| Me ₂ S | MeSCH ₂ , Me ₂ SOSiMe ₃ | MeSCH ₂ , Me' | |
| Et ₂ S | EtSCHMe, Et, SOSIMe, | EtSCHMe. Et* | |
| i-Pr ₂ S | i-PrSCMe ₂ , i-Pr ₂ SOSiMe ₃ | i-PISCMe2, i-PI | |
| t-Bu ₂ S | d | Et ₃ Si [•] | |
| CH2(CH2)3S | CH(CH ₂) ₃ S | CH(CH ₂) ₃ S, Et ₃ SiS(CH ₂) ₃ CH ₂ ^e | |
| t-BuSMe | t-BuSCH ₁ , t-Bu(Me)SOSiMe ₃ | t-BuSCH ₂ , t-Bu | |
| t-BuSPr-i | t-BuSCMe ₂ , t-Bu(i-Pr)SOSiMe ₃ | t-BuSCMe ₂ , t-Bu [*] , Et ₃ Si ^{* f} | |

^a A signal from a radical having the structure ${}^{\circ}CH_2OSi \equiv [3]$ was also detected in most systems. ^b Signals from persistent alkyl radicals were detected after prolonged photolysis, especially for the sulphides with bulky alkyl groups. ^c [(R₂CH)₂S] 0.5-2 M, [Et₃SiH] 2-5 M. ^d Apart from the spectrum due to ${}^{\circ}CH_2OSi \equiv$, some unidentified weak signals were present; no spectrum ascribable to t-Bu₂SOSiMe₃ was observed. ^ea(2H_a) 22.1, a(2H_b) 28.4, a(2H_y) 0.75 G. ^f [t-Bu⁺]/[i-Pr⁺] > 10 at 213 K.

TABLE 2

ESR PARAMETERS FOR SULPHURANYL RADICALS OF THE TYPE II IN CYCLOPROPANE AT ca. 213 K

| Radical | g-Factor | Hyperfine splittings (G) |
|---|----------|---|
| (CH ₃) ₂ SOSiMe ₃ | 2.0076 | a(6H) 7.7 ^a |
| (MeCH ₂), SOSiMe ₃ | 2.0074 | a(2H ¹) 7.2, a(2H ²) 10.0 |
| (Me ₂ CH) ₂ SOSiMe ₃ | 2.0075 | a(2H) 7.4 ^b |
| t-Bu(CH ₃)SOSiMe ₃ | 2.0074 | a(3H) 7.7 |
| t-Bu(Me, CH)SOSiMe | 2.0074 | a(1H) 5.2 |

^a A further splitting into an even number (≥ 6) of lines, spacing ca. 0.2 G, was detected under high resolution and assigned to the nine protons of the Me₃Si group. The spectrum from $(CD_3)_2S$ showed similar fine structure. ^b Central line broadens relative to the outer lines below 173 K, indicating non-equivalence of the two α -protons.

(3)

(4)

C22

or the radical could be "T-shaped" with non-equivalent, but rapidly exchanging, apical and equatorial alkyl groups [1,4]. The non-equivalent methylene protons in Et_2 SOSiMe₃ and the temperature-dependence of the spectrum assigned to i- Pr_2 SOSiMe₃ (see Table 2) can be explained on the basis of either structure, although we favour the former of these.

A third type of behaviour, namely rapid $S_{\rm H}2$ reaction at sulphur, which may or may not proceed by way of a discrete sulphuranyl radical intermediate, was observed by ESR spectroscopy when triethylsilyl radicals were generated in the presence of dialkyl sulphides. Photolysis of a cyclopropane solution containing the sulphide, di-t-butyl peroxide, and triethylsilane gave rise to overlapping spectra of the radicals R_2CH and I. At a given temperature, the ratio $[R_2CH]/[I]$ increases as $[Et_3SiH]/[(R_2CH)_2S]$ increases indicating a competition between reactions 2 and 5.

t-BuO[•] + Et₃SiH \longrightarrow t-BuOH + Et₃Si[•] (5) Et₃Si[•] + (R₂CH)₂S \longrightarrow Et₃SiSCHR₂ + R₂ĊH (6)

The rates of silyldealkylation of dialkyl sulphides are sensitive to steric crowding at sulphur, for example t-butyl radicals are displaced much more rapidly from t-BuSMe or t-BuSPr-i than from t-Bu₂S (see Table 1). Analogous $S_{\rm H}2$ reactions between trimethylsilyl radicals and dialkyl selenides or tellurides have recently been detected by ESR spectroscopy [5].

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